



Intro to Sigray

Founded in 2013

- **Dr. Wenbing Yun**, founded Xradia, now Carl Zeiss Microscopy, OSA Fellow and serial entrepreneur, and **Sylvia Lewis**

Mission: Dev. next generation x-ray technologies to Lab. and Fab.

Our Technology:

- Strong IP: 66 patents, 30+ pending, many trade secrets
- Disruptive x-ray components (source & optics)
- 5 world leading product families

Rapidly Growing: >60% Y/Y over 3 years

- 34k sq. ft. of manufacturing space in Concord, CA (San Francisco Bay Area) and 86 employees
- Global installation base of leading universities and companies (semiconductor & pharma)



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Suite of World Leading X-ray Systems

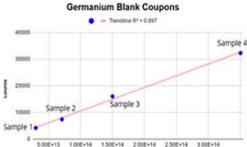
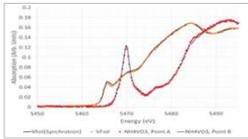
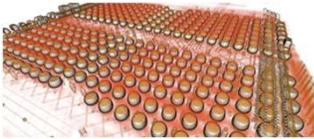
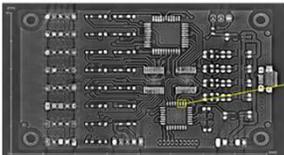


AttoMap microXRF
 Highest sensitivity to low Z
 Highest resolution microXRF

QuantumLeap XAS
 Only commercial f-XAS
 Highest quality EXAFS

EclipseXRM
 Highest resolution (0.3µm spatial) 3D
 x-ray microscope on the market

Apex XCT
 Highest throughput 3D x-ray tool
 (>1000X) for semi

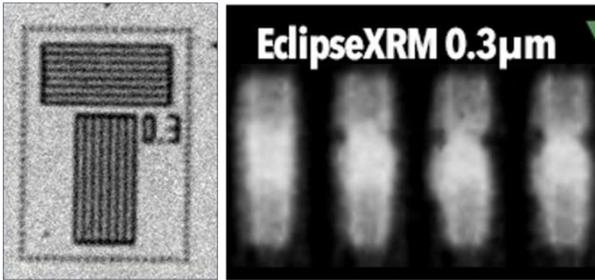
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Leading Lab Instruments for Semiconductor

Eclipse XRM and Apex XCT

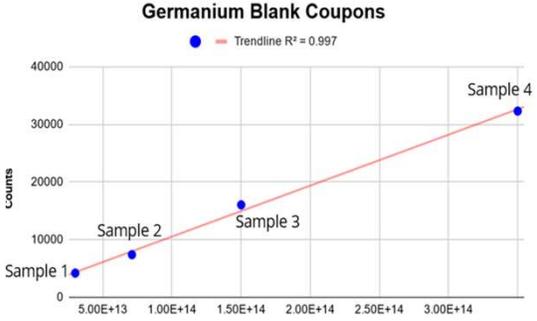
Received and expecting multiple POs
 Eclipse: Highest (0.3µm) resol. meeting the most challenging requirements
 Apex: Best 3D imaging system for large (300 mm wafer) 3D package applications



Attomap XRF

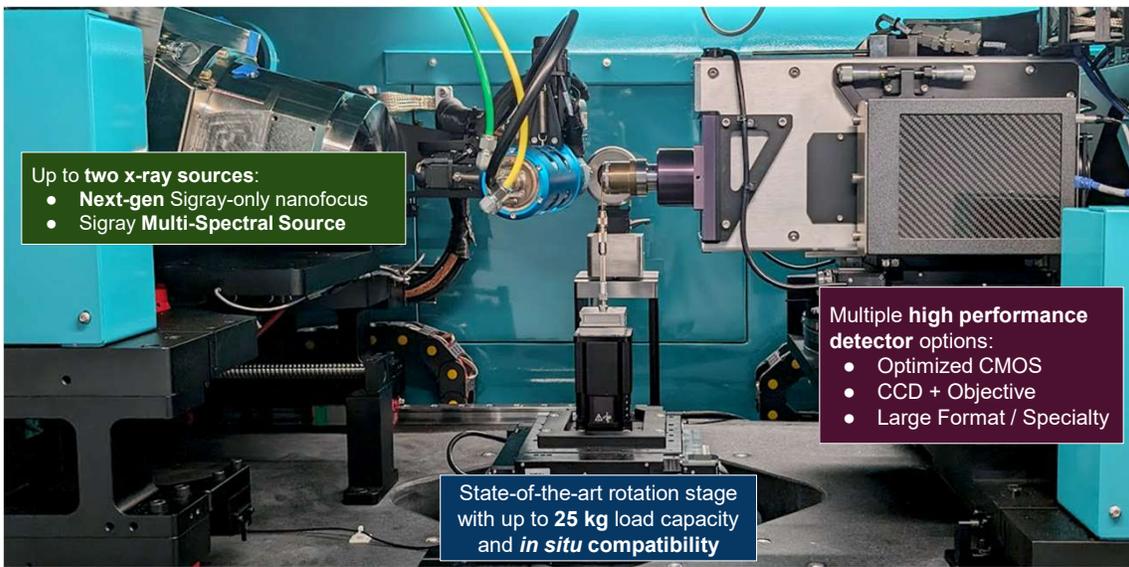
Multiple installations in two major companies
 Highest sensitivities materials/thin-film metrology, e.g., 0.1 atomic layer measurement,

Germanium Blank Coupons



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EclipseXRM Interior



Up to two x-ray sources:

- Next-gen Sigray-only nanofocus
- Sigray Multi-Spectral Source

State-of-the-art rotation stage with up to 25 kg load capacity and *in situ* compatibility

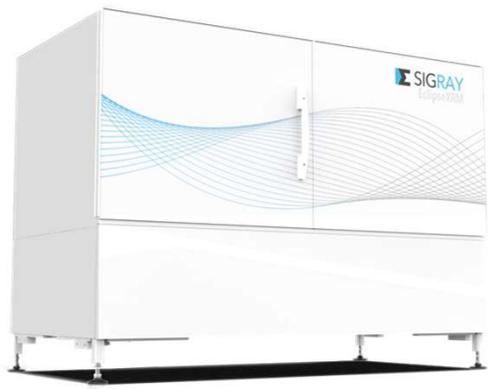
Multiple high performance detector options:

- Optimized CMOS
- CCD + Objective
- Large Format / Specialty

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EclipseXRM Options

Configurations for Next-Generation Capabilities



Switchable Multi-Spectral Source (MSS)

Detector Options

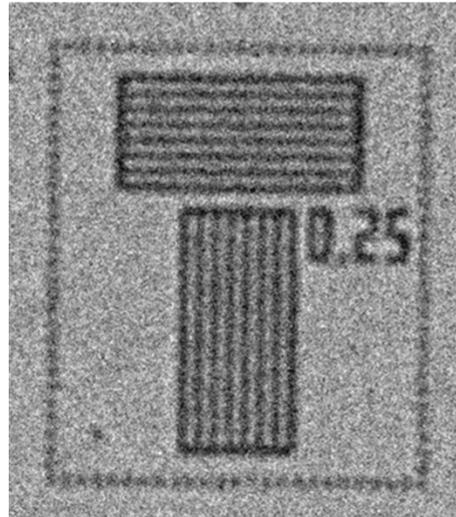
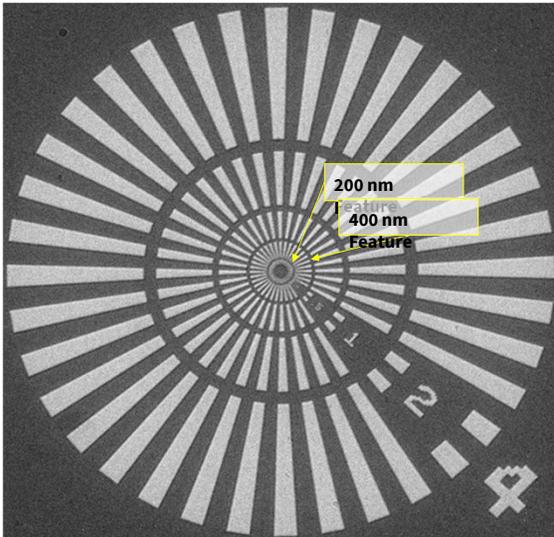
Robotic Sample Handling

Tomography Modes (Helical, Offset)

User-Friendly Software

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Achieving 300nm 3D with Prisma and Apex

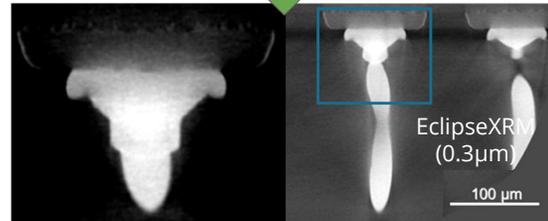
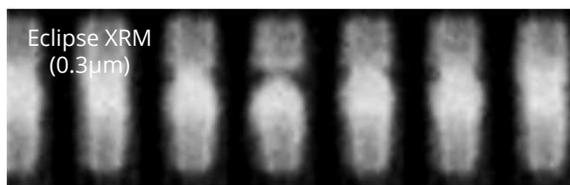
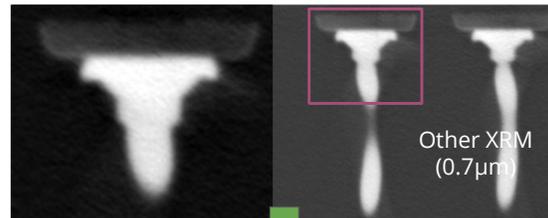
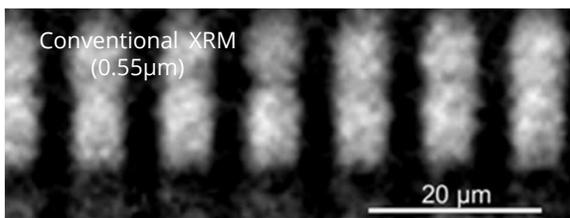


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Resolution & Contrast Improvements

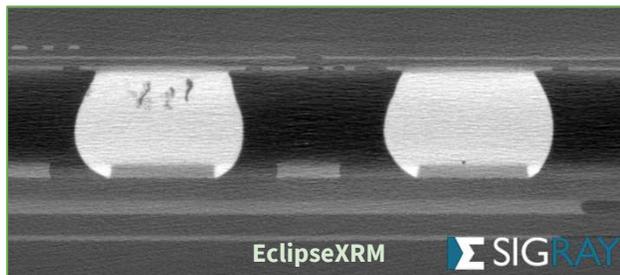
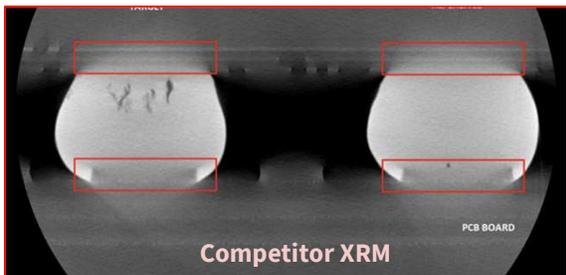
Semiconductor Examples: Other CT systems (top) and EclipseXRM (bottom)



Ultra-challenging microbumps (~6µm)

BGA Inspection: Cracks & Delamination

Clear Images, Superior to Competition | EclipseXRM with Nanofocus Source

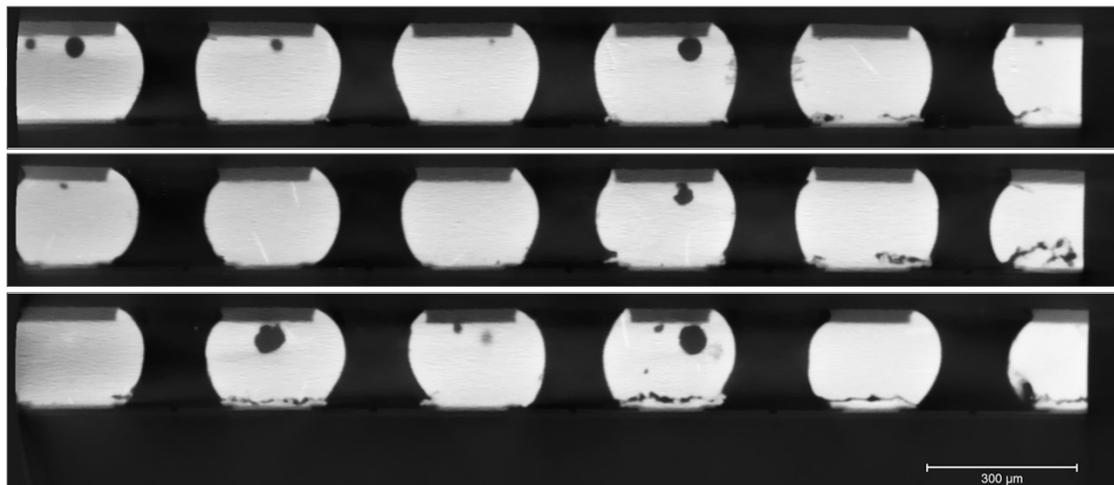


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BGA Inspection in 3D

Cross-Sectional Views (Sagittal Plane) | EclipseXRM with Nanofocus Source

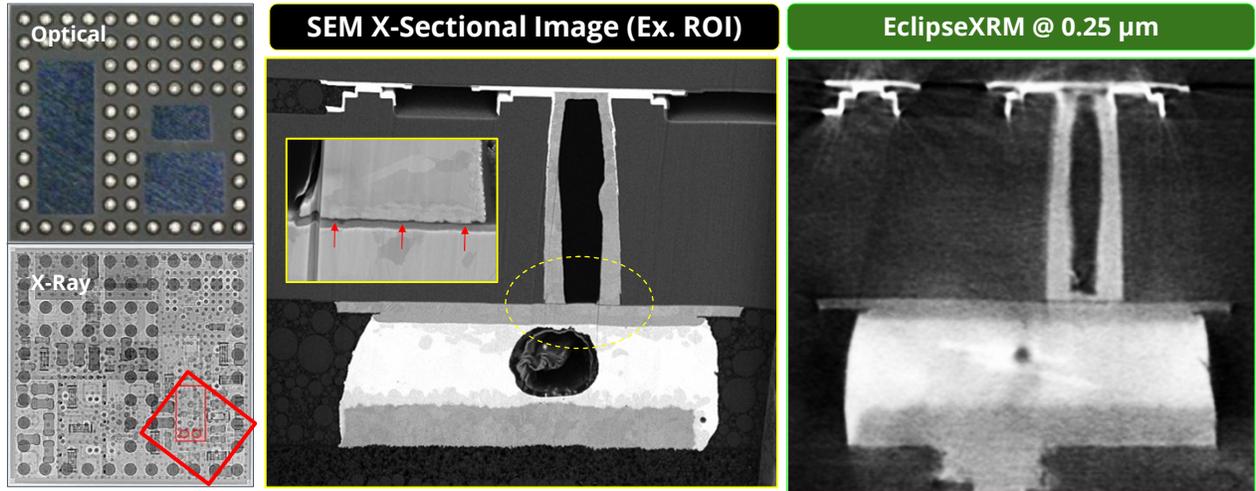


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Package Inspection at Via Connection

Via Interface Separation: 12 hrs @ 0.25 μm

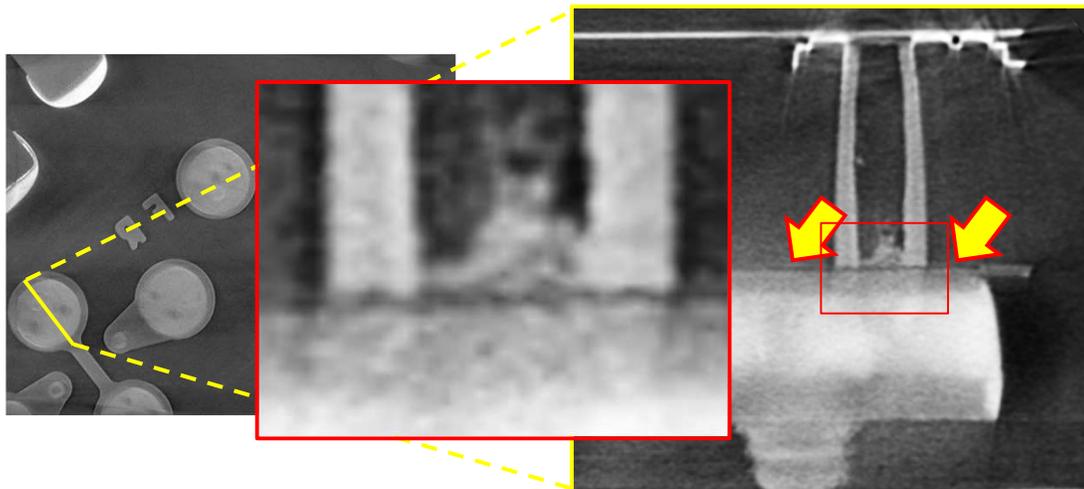


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Crack/Delamination at Via Interconnect

Virtual Slice Inspection: 12 hrs @ 0.25 μm

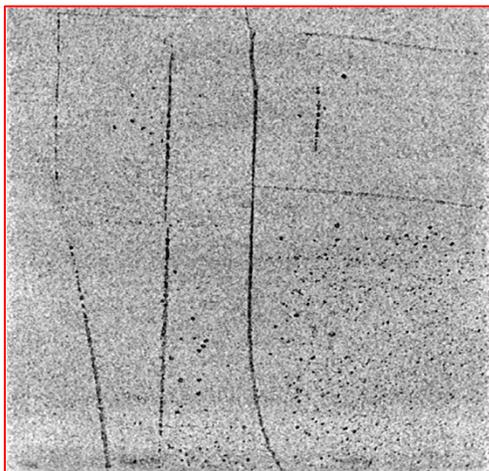


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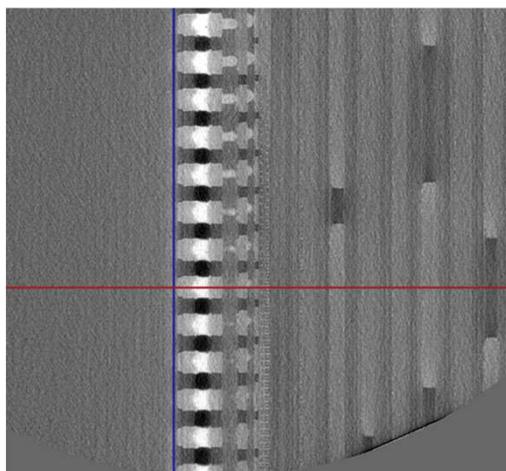


Achieving 300nm 3D with Eclipse and Apex

Imaging Si die cracks



Imaging micro-bumps



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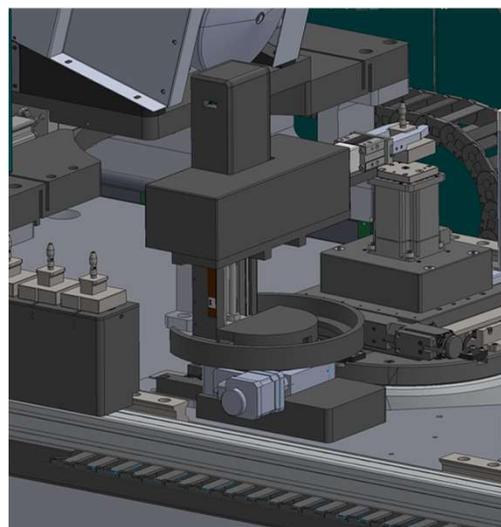
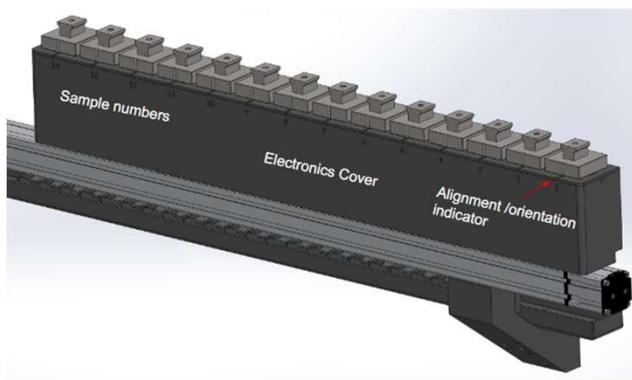


Robotic Sample Handling

Up to 14 Sample Positions (50mm Each)

Design based on Apex robotic sample handler used at semiconductor companies

Robot

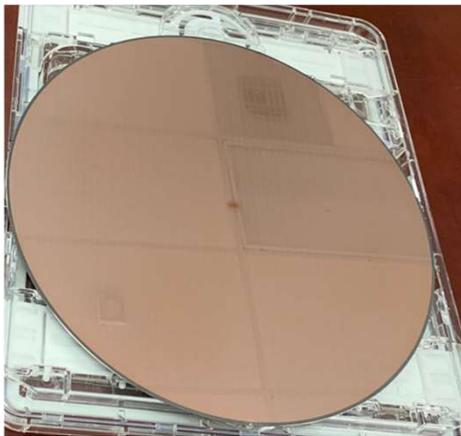


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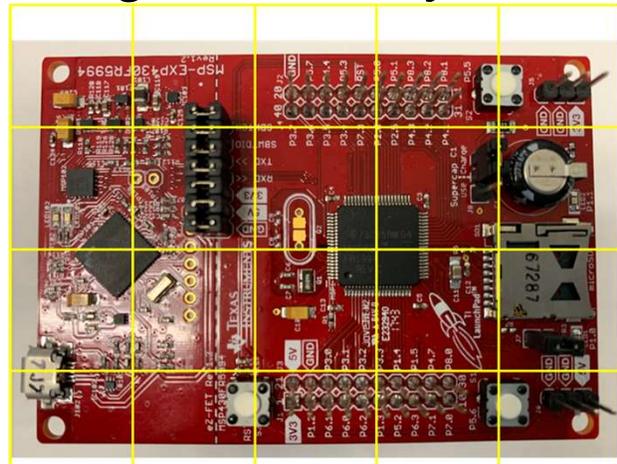
APEX-XCT: Optimized 3D for Large Planar Objects

- *0.5um Resolution and <0.3um Voxel*
- *3D imaging in minutes of large planar objects*
- *Negligible radiation hardening artifacts*
- *High speed reconstruction*
- *Advanced algorithms for defect detection*
- *Automated montage multiple 3D imaging*
- *Numerous successful competitive demos*

Need of Fast 3D Imaging of Large Planar Objects



Microbumps and TSVs on 300mm Wafer



Bumps and circuitry of large PCB boards

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Challenges of Conventional XCT

Unacceptably Long Exposure Times and Radiation Hardening Artifacts for Large Samples

Larger samples require increased source-detector distances, which **reduce X-ray flux** by $1/r^2$ and **increase exposure times**.

Exposure Time for 0.5um imaging

← Faster (Better)

Specimen Size

Wafers

Boards

Chips

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Computed Laminography (CL): Optimal for Large Planar Objects

- High throughput due to short source-ROI distance,
- Drastically less radiation hardening artifacts
- Large PCBs and wafers

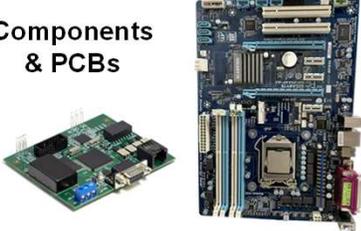
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Scalable Technology with Apex XCT

Non-Destructive Inspection Capabilities: From PCBs to Full Wafers

Sample Types

Components & PCBs



Wafers up to 300 mm+



Inspection Workflows

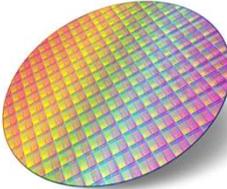
Defect	Good Solder Joint	Non Wet	Non Contact	Head in Pillow	Voids	Solder/RDL Crack	Die/Molding Compound Crack	Bridging	Warpage
									
Apex XCT	Y	Y	Y	Y	Y	Y	Y	Y	Y

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SIGRAY

Key Applications & Sample Types

Focus on Electronics Segment: Large, Flat Samples



Wafers (Up to 300 mm)



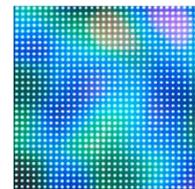
Integrated Devices (PCBs, Modules)



Large Packages



NDT / Large Integrations

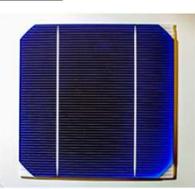


Advanced Modules (e.g. LEDs)

Dev Lab



Pouch Batteries



Solar Cells

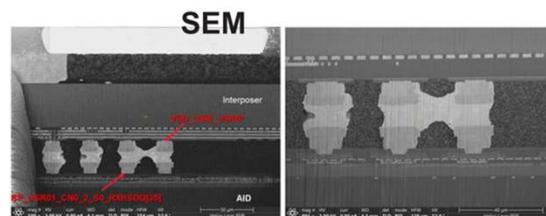
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Bridging Demo: Intact Die

Identifying Bridge Defect

	High res	Throughput
Total integration time	30 mins	12 mins
Voxel Size	0.5 μm	2.5 μm
Field of View	1.47 x 1.15 mm	7.35 x 5.75 mm

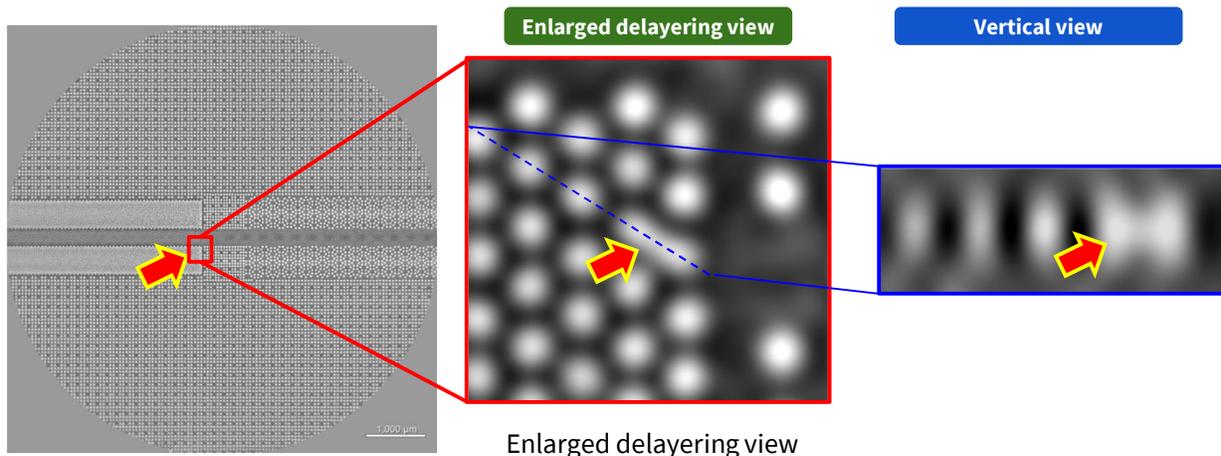


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Accelerating Throughput @ 12 mins

A close examination of the solder melt in both delayering and vertical perspectives

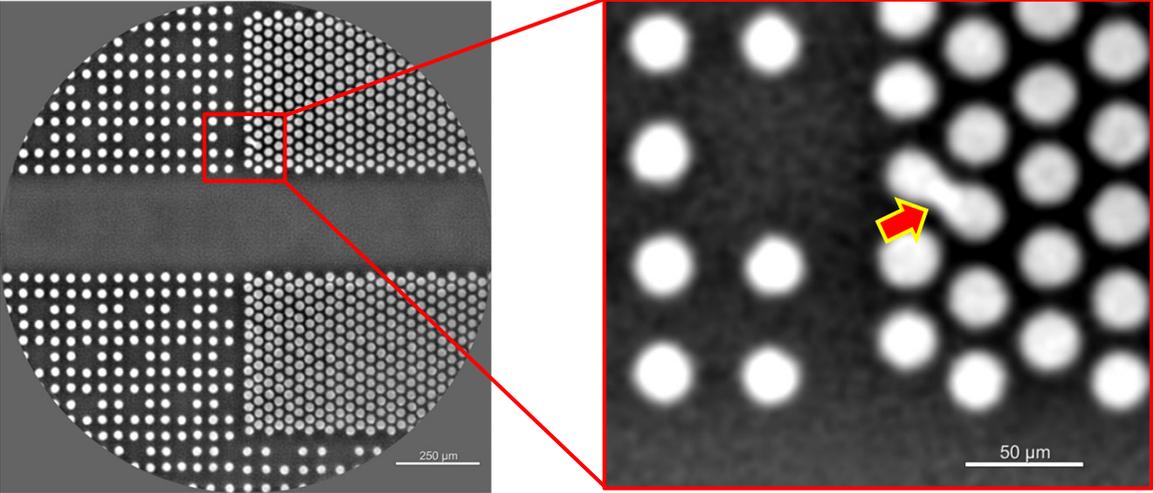


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Bridging: High Res Scan @ 0.5 μm

Slicing through 3D volume data in a delayering perspective.



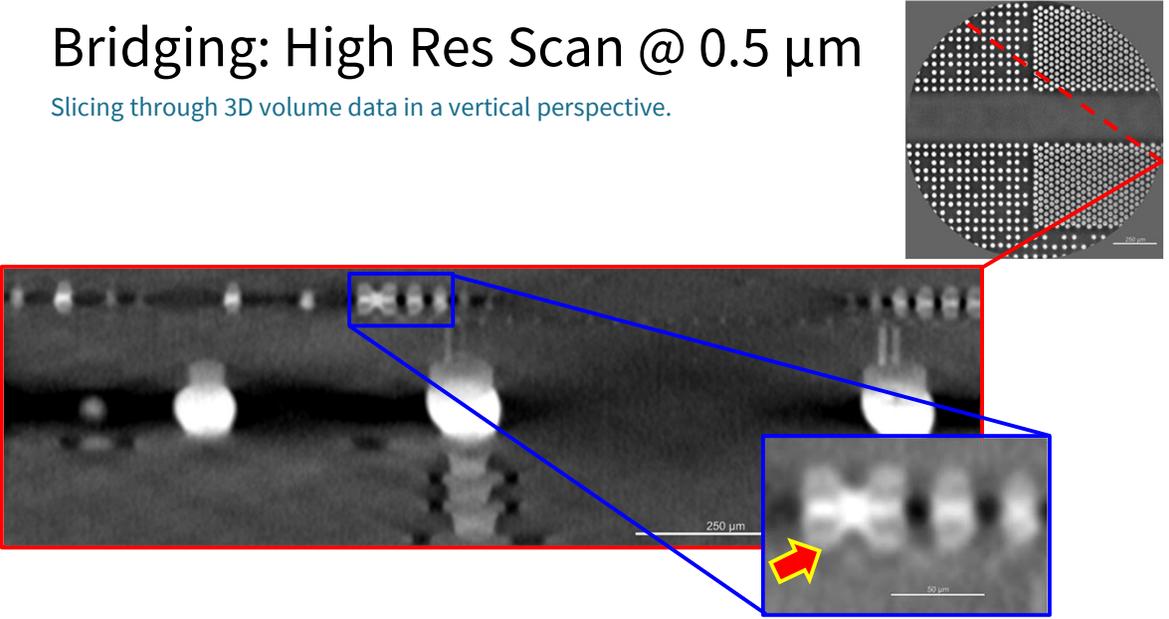
The image shows a circular array of vias. A red box highlights a specific area, which is magnified in the right-hand image. In the magnified view, a yellow arrow points to a white bridge between two adjacent vias. Scale bars are provided for both views: 250 μm for the full array and 50 μm for the magnified view.

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Bridging: High Res Scan @ 0.5 μm

Slicing through 3D volume data in a vertical perspective.



The image shows a vertical cross-section of the vias. A red dashed box highlights a specific area, which is magnified in the bottom-right image. In the magnified view, a yellow arrow points to a white bridge between two adjacent vias. Scale bars are provided for both views: 250 μm for the full array and 50 μm for the magnified view.

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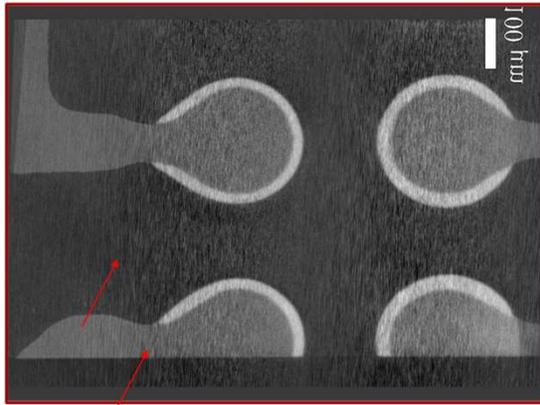


Cracks, voids, defects in Organic Layer

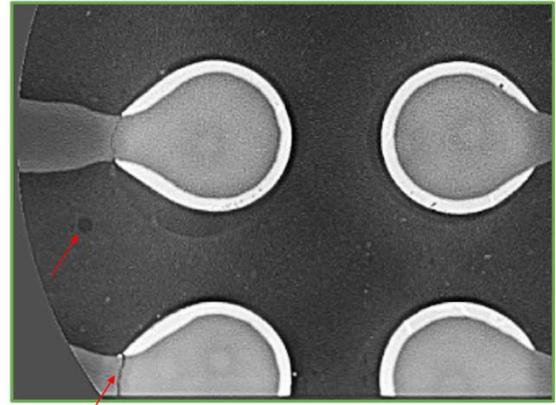
Conventional XRM (4 hours)

vs

Apex XCT (30 min)



Poor signal to noise
~4 hour measurement time
Difficult to see cracks

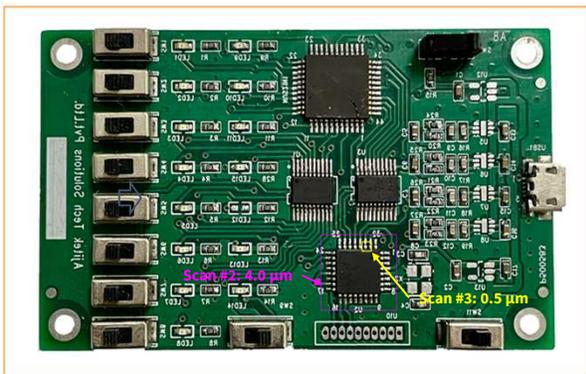


Excellent signal to noise
30 min measurement time
Easily resolves cracks

Multi-Scale Imaging

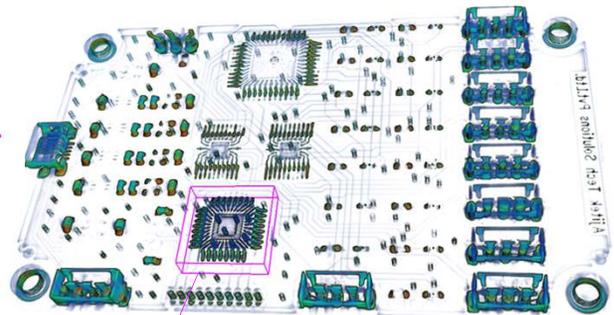
8.0 → 4.0 → 0.5 μm Resolution

Scan #1 : 8.0 μm Montage

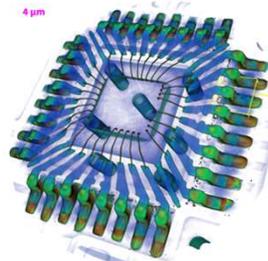


Intact PCB (50 mm x 100 mm)

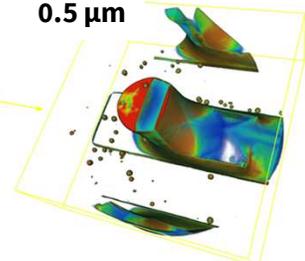
4 μm



4 μm

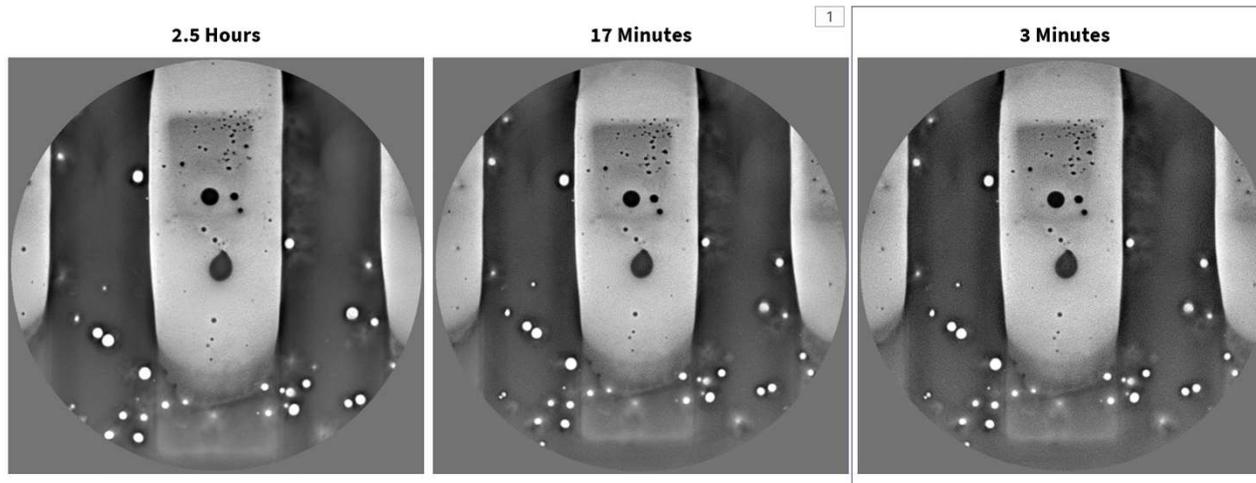


0.5 μm



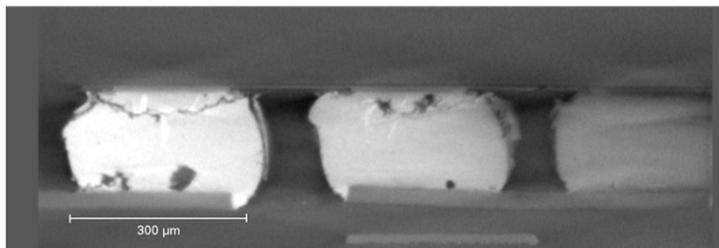
0.5 μm - Exposure Time Comparison

Example Virtual Slice - Intact PCB (50 mm x 100 mm)

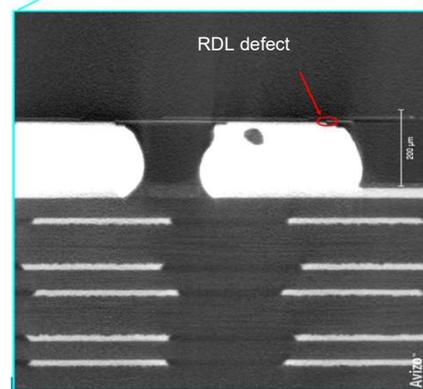
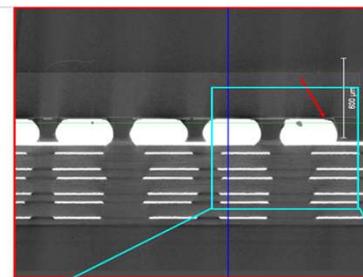


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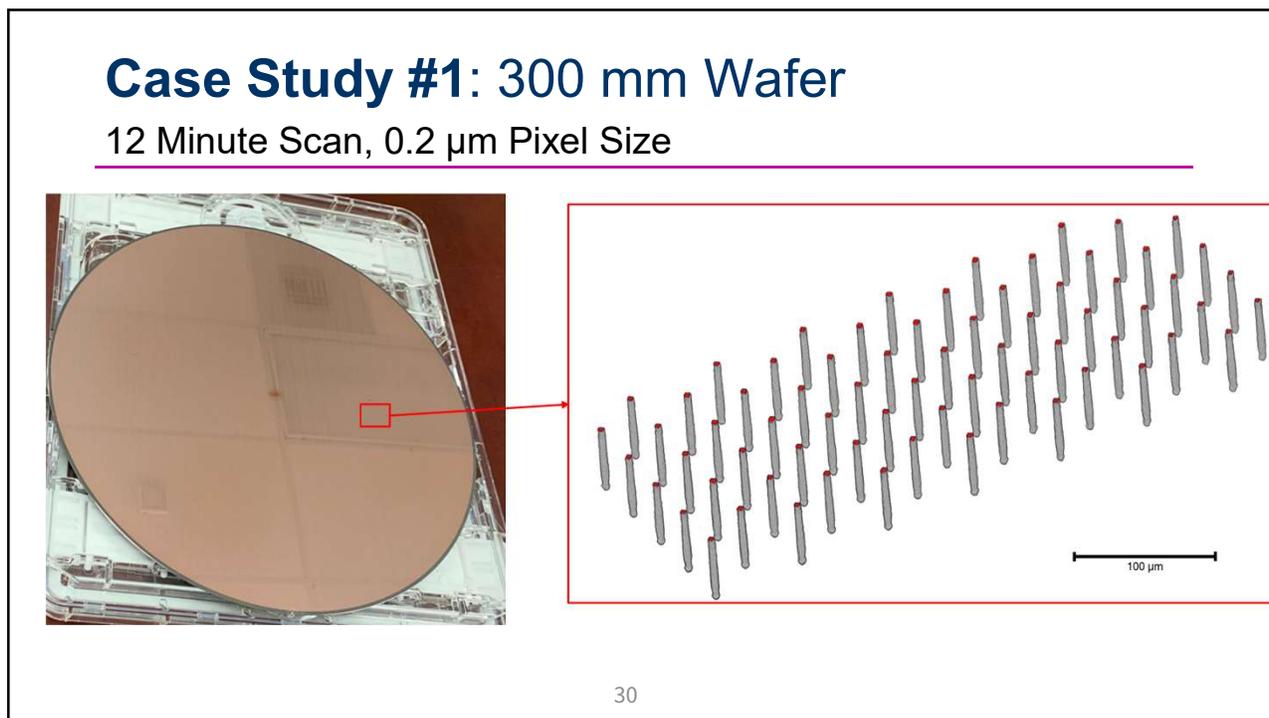
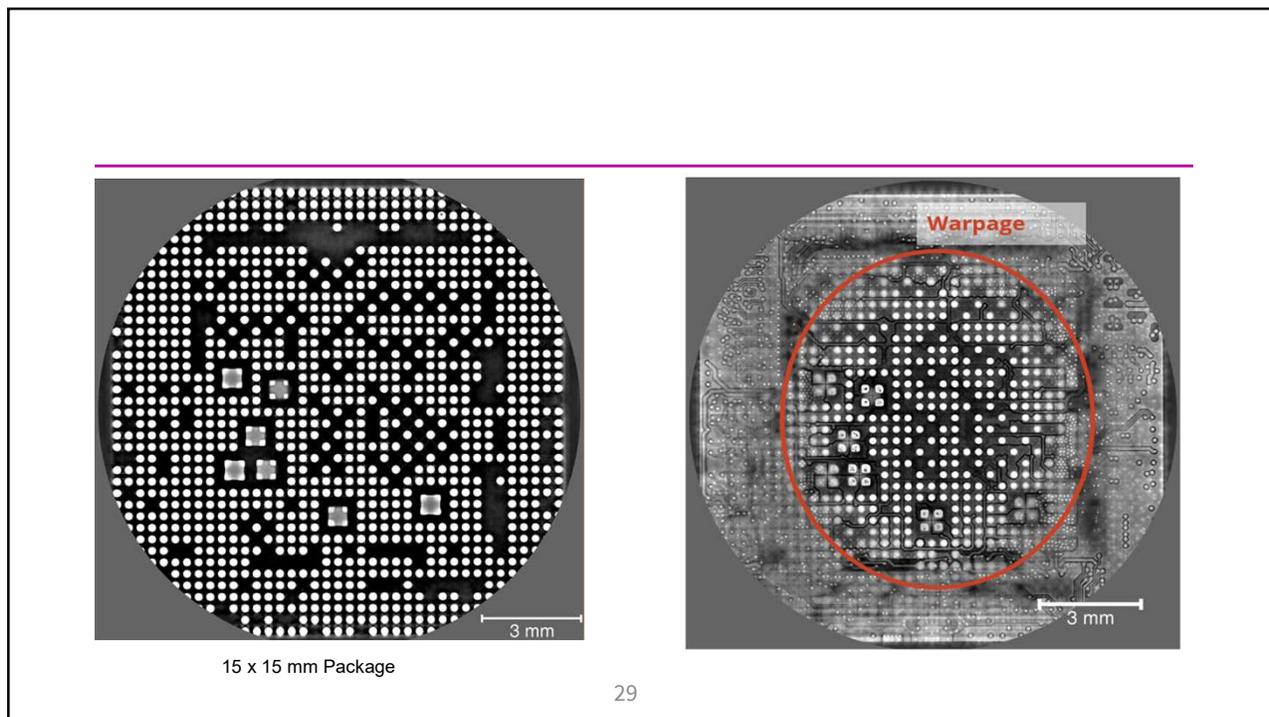
Rapid Stress Crack Detection to RDL defects in minutes

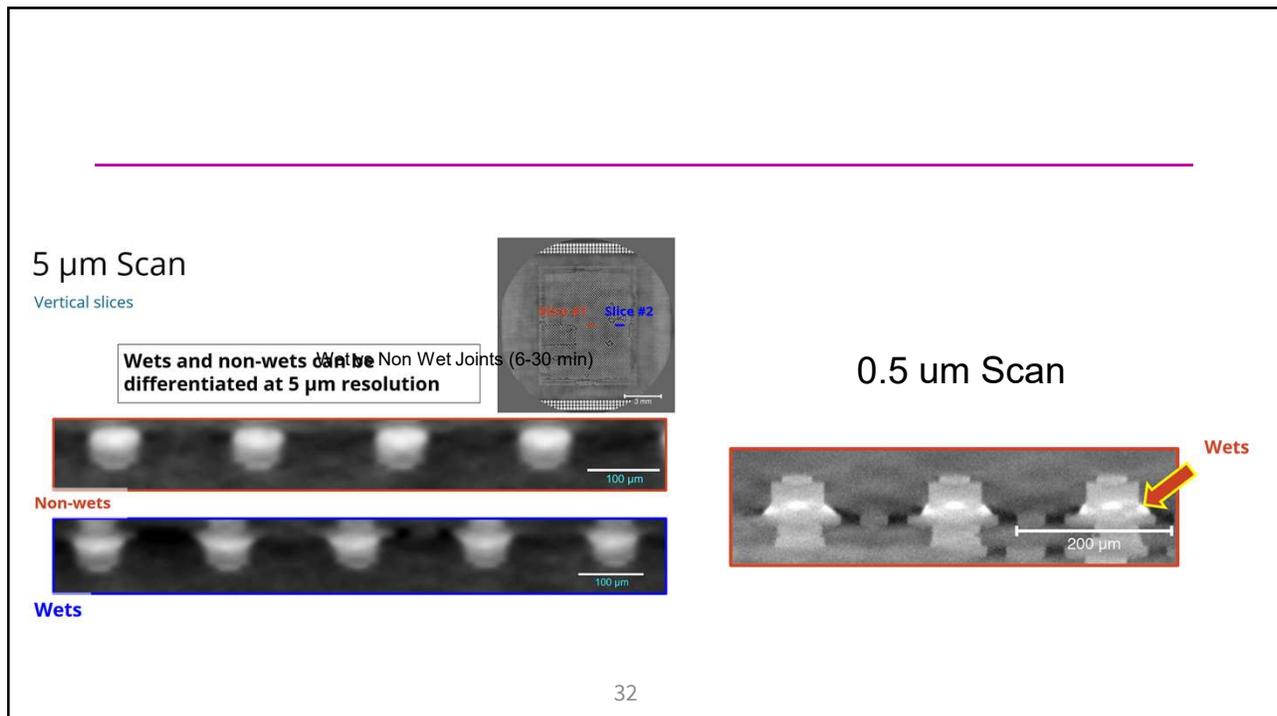
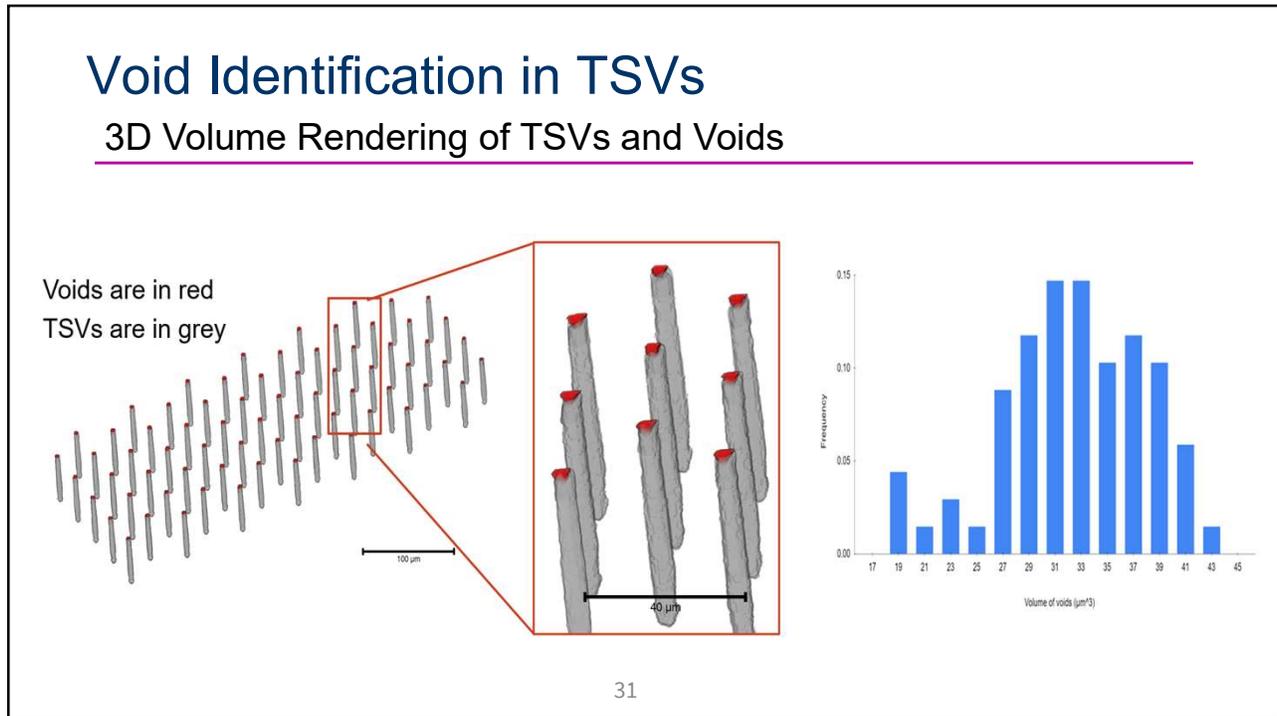


Rapid Stress Evaluation 5 min Scan after Burn in

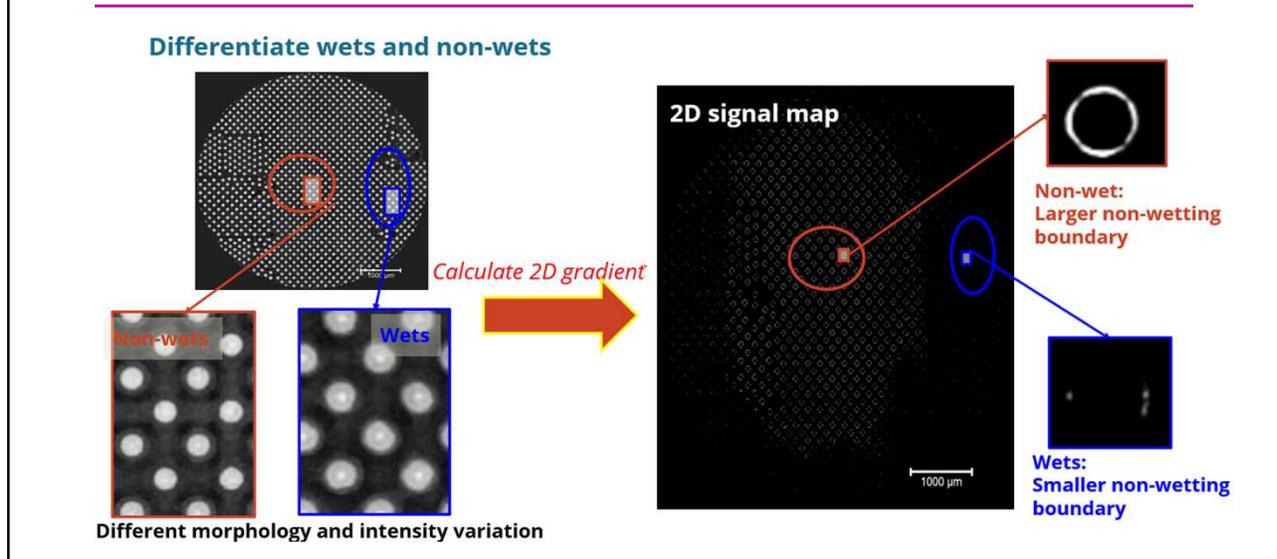


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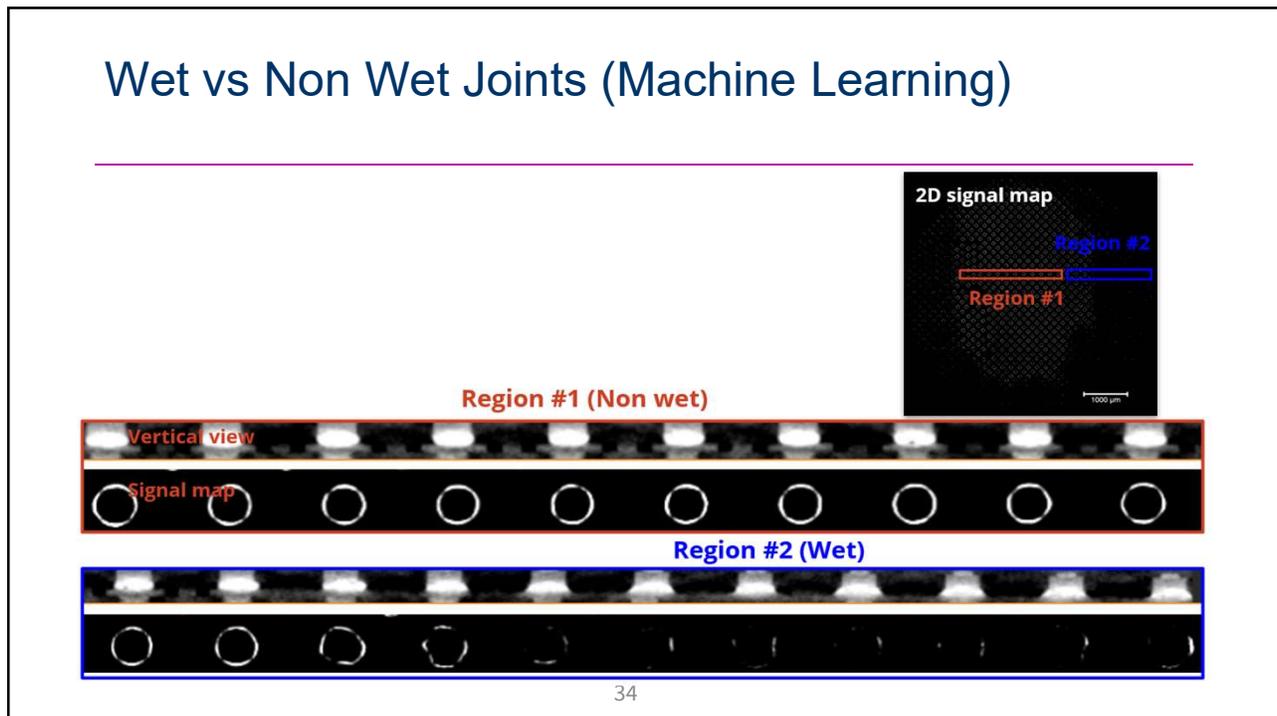




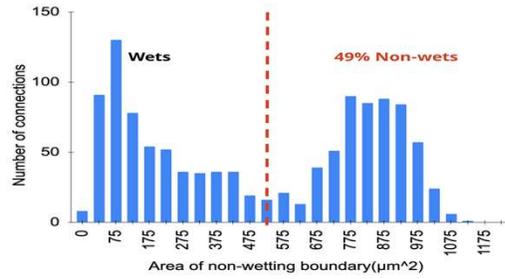
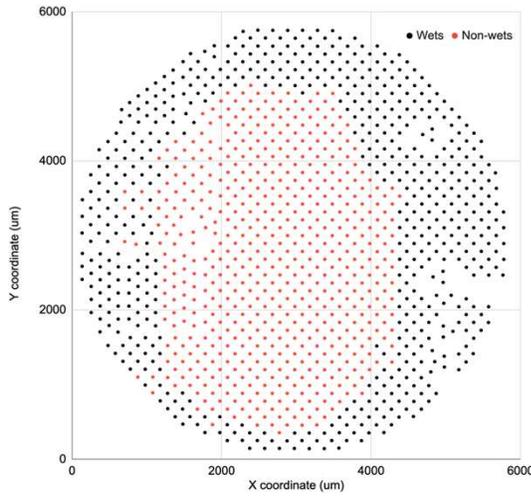
Wet vs Non Wet Joints



Wet vs Non Wet Joints (Machine Learning)



Statistics: Wet vs Non Wet Joints



- ❑ The wetting status and locations of **1187** joints were analyzed **< 6 min**.
- ❑ 575 non-wets were detected
- ❑ The **distribution pattern** of non-wets is consistent with the **warpage** of the layer

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Apex XCT-in-Line

In-line System for Advanced Packaging



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